

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of: Kaisaki et al.


Group Art Unit:

Serial No.:

Filed:

Examiner:

For: METHOD OF MODIFYING A WAFER SUITED FOR SEMICONDUCTOR  
FABRICATION

<b>Certificate of Express Mailing</b>	
Pursuant to 37 CFR 1.10 I certify that this application is being deposited on the date indicated below with the United States Postal Service "Express Mail Post Office to Addressee" service addressed to: Commissioner for Patents, Washington, DC 20231.	
Express Mail Mailing Label No. <b>EL509319492US</b>	Signature of Person Mailing Application 
Date of Deposit <b>November 6, 2000</b>	Printed Name of Person Mailing Application <b>Kara R. Welle</b>

**INFORMATION DISCLOSURE STATEMENT**

Commissioner for Patents  
Washington, DC 20231

Dear Sir:

Pursuant to 37 CFR §1.56 and §1.97-1.98, enclosed please find a completed Form PTO-1449 citing references submitted for consideration by the Examiner during examination of the above-referenced patent application.

In accordance with 37 C.F.R. § 1.98(d), only copies of those documents not previously cited and submitted to the Patent and Trademark Office in prior application serial No.: 09/091,932, which is a national stage application of international application No.: PCT/US98/08693 which is a continuation in part of application No.: 08/846,726 filed April 30, 1997 are enclosed.

Applicants request consideration of these references by the Examiner in regard to the present application, and that the Examiner initial and return the enclosed Form PTO-1449.

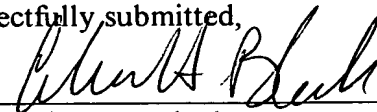
It is believed that no fee is due in connection with this Information Disclosure Statement; however, if any such fee is due, please charge to Deposit Account No. 13-3723.

Registration Number 41,056	Telephone Number (651) 737-2356
Date <i>November 6, 2000</i>	

Office of Intellectual Property Counsel  
3M Innovative Properties Company  
P.O. Box 33427  
St. Paul, Minnesota 55133-3427  
Facsimile: (651) 736-3833

Respectfully submitted,

By

  
Colene H. Blank